

PATENT

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant(s): Hamada et al.  
Filed: Concurrently Herewith  
Title: COMPOSITION FOR FORMING POROUS FILM AND METHOD FOR  
FORMING THE SAME, POROUS FILM AND METHOD FOR FORMING  
THE SAME, INTERLEVEL INSULATOR FILM, AND SEMICONDUCTOR  
DEVICE

Docket No.: 035576/275601  
Customer No.: 00826

March 9, 2004

Mail Stop Patent Application  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**PRELIMINARY AMENDMENT**  
**37 CFR § 1.115**

Sir:

Please enter this Preliminary Amendment before calculating the claim fee and amend the above-identified application as follows:

**Amendments to the Claims** are reflected in the listing of claims beginning on page 2 of this paper.

**Remarks** begin on page 7 of this paper.